

PATENT ABSTRACTS OF JAPAN

(11)Publication number : 2001-026052

(43)Date of publication of application : 30.01.2001

(51)Int.Cl. B29C 59/02

G02B 5/18

G02B 6/13

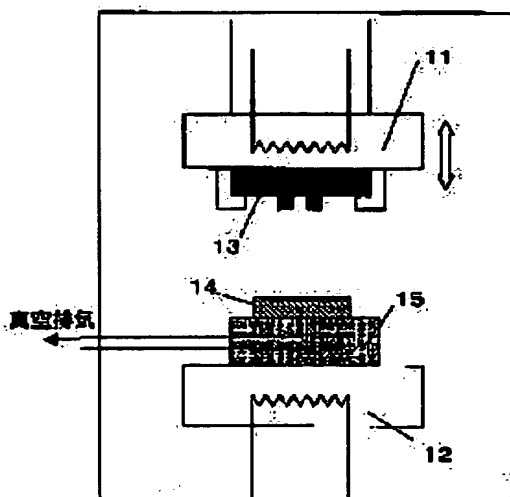
// B29L 11:00

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(54) TRANSFER OF MINUTE SHAPE AND MANUFACTURE OF OPTICAL PART

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(57)Abstract:

PROBLEM TO BE SOLVED: To transfer a highly precise and minute shape by a method wherein a mold containing an uneven pattern is prepared, and specific relations among a temperature at which the mold is pressed to a base material, a temperature at which the mold is separated from the base material, thermal expansion coefficients of the mold and the base material, and a maximum distance from a transfer center of a transfer face to the uneven pattern are simultaneously satisfied.

SOLUTION: Passing of electric current to the upper and lower heaters is controlled under the condition wherein an uneven pattern of a

quartz mold 13 is allowed to cut into a resin base 14, a temperature of the heater is lowered to 150° C, the upper heater block 11 is pulled up, and an upper mold 13 is forcibly separated from the resin base 14. It a temperature at which the quartz mold 13 is pressed to the resin base 14 is taken as T1° C, a temperature at which the quartz mold 13 is separated from the resin base 14 is taken as T2° C, thermal expansion coefficients of the quartz mold 13 and the resin base 14 are respectively taken as αa and αb , and a maximum distance from a transfer center of a transfer face to the uneven pattern is d mm, relations of $1/\alpha a - \alpha b \cdot 1 \cdot (T1 - T2) \cdot d \leq 4 \times 10^{-2}$ and $T1 \geq T2$ are made simultaneously satisfied.

LEGAL STATUS

[Date of request for examination] 13.07.1999

[Date of sending the examiner's decision of rejection]

[Kind of final disposal of application other than the examiner's decision of rejection or application converted registration]

[Date of final disposal for application]

[Patent number] 3229871

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[Date of registration]

07.09.2001

[Number of appeal against examiner's
decision of rejection]

[Date of requesting appeal against
examiner's decision of rejection]

[Date of extinction of right]

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